

FORM PTO-1449 (Rev. 2-3-2)	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTY. DOCKET NO. TUN-568US	SERIAL NO 10/007,575
Information Disclosure Statement by Applicant (Use separate sheets if necessary)		APPLICANT Rongjia Tao et al.	
		FILING DATE November 9, 2001	GROUP

RECEIVED
JAN 25 2002
10:17:00

JAN 16 2002
PATENT & TRADEMARK OFFICE

U.S. PATENT DOCUMENTS

Exmr Initial	Document Number	Date	Name	Class	Sub Class	Filing Date
	Re. 35,773	04/21/1998	Okada et al.			
	Re. 37,015E	01/16/2001	Rensel et al.			
	5,507,967	04/16/1996	Fujita et al.			
	5,558,803	09/24/1996	Okada et al.			
	5,843,331	12/01/1998	Schober et al.			
	5,891,356	04/06/1999	Inoue et al.			
	6,027,429	02/22/2000	Daniels			
	6,096,235	08/01/2000	Asako et al.			
	6,116,257	09/12/2000	Yokota et al.			
	6,149,166	11/21/2000	Struss et al.			
	6,159,396	12/12/2000	Fujita et al.			

FOREIGN PATENT DOCUMENTS

Exmr Initial	Document Number	Date	Country	Class	Sub Class	Translation YES NO

OTHER DOCUMENTS

(Including Author, Title, Date, Pertinent Pages, Etc.)

1)	R. Tao et al., "Three-Dimensional Structure of Induced Electrorheological Solid", Phys. Rev. Lett., Vol. 67, No. 3, 15 July 1991, pps. 398-401
2)	Chen et al., "Laser Diffraction Determination of the Crystalline Structure of an Electrorheological Fluid", Phys. Rev. Lett., Vol. 68, No. 16, 20 April 1992, pps. 2555-2558
3)	G.L. Gulley et al., "Static Shear Stress of Electrorheological Fluids", Phys. Rev. E, Vol. 48, No. 4 October 1993, pps. 2744-2751
4)	X. Tang et al., "Structure-enhanced Yield Stress of Magnetorheological Fluids", J. of Applied Physics, Vol. 87, No. 5, 1 March 2000, pps. 2634-2638
5)	R. Tao et al., "Electrorheological Fluids Under Shear", International J. of Modern Physics B, Vol. 15, 2001

Examiner b. h. j.	Date Considered 3/18/04
----------------------	----------------------------

Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

RECEIVED
MAR 19 2003
GROUP 17005

RECEIVED
MAR 19 2003
GROUP 17005

RECEIVED
MAR 19 2003
GROUP 1700

RECEIVED
MAR 19 2003
GROUP 1700

RECEIVED
MAR 19 2003
GROUP 1700

RECEIVED
MAR 19 2003
GROUP 1700

RECEIVED
MAR 19 2003
GROUP 1700

RECEIVED
MAR 19 2003
GROUP 1700

RECEIVED
MAR 19 2003
GROUP 1700

RECEIVED
MAR 19 2003
GROUP 1700